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APPLICATION NO.	FILI	NG DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/763,365 02/23/2001		/23/2001	Teruo Takizawa	108680	4673
25944	7590	04/23/2003			
OLIFF & BE	ERRIDGE	E, PLC	EXAM	EXAMINER	
P.O. BOX 19928 ALEXANDRIA, VA 22320			HOGANS,	HOGANS, DAVID L	
				ART UNIT	PAPER NUMBER
				2813	· · · · · · · · · · · · · · · · · · ·

DATE MAILED: 04/23/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	$\overline{\lambda}$
Office Action Summary	09/763,365	TAKIZAWA ET AL.	/ 1
· ·	Examiner	Art Unit	
Th. MAN WOOD TO A STATE OF THE	David L. Hogans	2813	
Th MAILING DATE of this communication app Period for Reply	ars on the cover she twith the co	orrespondenc add	ress
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply if NO period for reply is specified above, the maximum statutory period with Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	6(a) In no event, however, may a reply be time within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from t	ely filed will be considered timely he mailing date of this com	ımunication
1) Responsive to communication(s) filed on 26 Fe	ebruary 2003 .		
2a) This action is FINAL . 2b) ⊠ This	s action is non-final.		
Since this application is in condition for allowar closed in accordance with the practice under E Disposition of Claims	nce except for formal matters, pro	osecution as to the 53 O.G. 213.	merits is
4) Claim(s) 17-27 is/are pending in the application	1,		
4a) Of the above claim(s) is/are withdraw			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>17-27</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/or	election requirement		
Application Papers	ciccion requirement.		
9) The specification is objected to by the Examiner.			
10) The drawing(s) filed on 23 February 2001 is/are:	a) accepted or b) objected to b	w the Evaminar	
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	37 CED 1.95(a)	
11) The proposed drawing correction filed oni	s: a) approved b) disapprov	ed by the Evaminer	
If approved, corrected drawings are required in reply	to this Office action	cd by the Examiner.	
12) The oath or declaration is objected to by the Exar			
Priority under 35 U.S.C. §§ 119 and 120			
13) Acknowledgment is made of a claim for foreign p	priority under 35 H.S.C. & 110(a)	(d) or (f)	
a)⊠ All b)□ Some * c)□ None of:	monty under 55 0.5.6. § 115(a)-	(d) or (i).	
1.⊠ Certified copies of the priority documents I	have been roccived		
Certified copies of the priority documents to		- N.	
 3. Copies of the certified copies of the priority application from the International Bure. * See the attached detailed Office action for a list of 	au (PCT Rule 17 2(a))		ige
14) Acknowledgment is made of a claim for domestic			onlication)
 a) The translation of the foreign language provis 15) Acknowledgment is made of a claim for domestic 	sional application has been receiv	ved.	phoduotiy.
ttachment(s)	,		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	4) Interview Summary (F 5) Notice of Informal Pat 6) Other:	PTO-413) Paper No(s) ent Application (PTO-1	52)

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DETAILED ACTION

This Office Action is in response to Amendment D filed on February 26, 2003.

Status of Claims

Claims 1-16 are cancelled. Claims 17-27 are newly added.

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 17-20 and 22-26 are rejected under 35 U.S.C. 103(a) as being unpatentable over 6,124,614 to Ryum et al.

Claims 17, 18 and 22-24

Ryum et al., in columns 4-5 lines 10-40 and Figures 3A-3F, teaches a semiconductor device comprising: a silicon substrate (51-1); a gate insulation film (53) on the silicon substrate; a gate electrode (540) on the gate insulation film, the gate electrode including a polycrystalline germanium film on the gate insulation film; wherein impurities are doped into the germanium film.

Ryum et al. discloses the claimed invention except for the impurities being of a ptype and within a concentration range of about 10^{17} to 10^{20} cm⁻³. _Art Unit: 2813

It would have been obvious to one of ordinary skill in the art at the time the invention was made to optimize the concentration range of impurities, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. *In re Aller*, 105 USPQ 233 (CCPA 1955)

Claims 19, 20 and 25-26

Incorporating all arguments of Claims 17 and 22 and noting that Ryum et al., in column 5 lines 15-40 and Figures 3A-3F, teaches wherein the gate electrode (540) includes a low resistance conductive film comprised of a metal silicide.

Furthermore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to select a preferred metal silicide, since it has been held to be within the general skill of a worker in the art to select a known material based on its suitability for its intended use. *In re Leshin*, 125 USPQ 416 (CCPA 1960)

3. Claims 21 and 27 are rejected under 35 U.S.C. 103(a) as being unpatentable over 6,124,614 to Ryum et al. in view of <u>Semiconductor Manufacturing Technology</u> (2001) to Quirk et al.

_Art Unit: 2813

Incorporating all arguments of Claims 17, 19, 22 and 25 and noting that Ryum et al. fails to explicitly teach a wherein the multi-layer structure is provided with a polysilicon film in between the germanium film and the low resistance conductive film.

However, Quirk et al., on pages 309-311, teaches a polysilicon film that is covered with a refractory metal. Furthermore, Quirk et al. teaches that when the polysilicon and the refractory metal are alloyed together they form a silicide that exhibits low electrical resistivity (i.e. – polycides reduce the series resistance of an interconnection to a polysilicon gate) and are thermally stable.

It would have been obvious to one of ordinary skill in the art to modify Ryum et al. by incorporating a polysilicon layer beneath the low resistance conductive film, as taught by Quirk et al., to provide a low electrical resistivity silicide contact to a gate.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David L. Hogans whose telephone number is (703) 305-3361. The examiner can normally be reached on M-F (7:30-4:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on (703) 308-4940. The fax phone numbers for the organization where this application or proceeding is assigned are (703)

308-7722 for regular communications and (703) 308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-1782.

dh April 16, 2003

CARL WHITEHEAD, JR.
UPERVISORY PATENT EXAMINES
TECHNOLOGY CENTER 2800